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APPLICATION N	Ю.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/692,075		10/19/2000	Ken Harris	-	6304	
23413	7590	10/28/2002				
		URN, LLP	ſ	EXAMINER		İ
55 GRIFFIN ROAD SOUTH BLOOMFIELD, CT 06002			•	ANGEBRANNDT, MARTIN J		
			1	ART UNIT	PAPER NUMBER	11
			•	1756		<u> </u>
			DATE MAILED: 10/28/2002	2		

Please find below and/or attached an Office communication concerning this application or proceeding.

			Gr.				
. Ap	pplication No.	Applicant(s)					
0:	9/692,075	HARRIS, KEN					
Office Action Summary	aminer	Art Unit					
Ma	artin J Angebranndt	1756					
The MAILING DATE of this communication appears Period for Reply	s on the cover sheet with t	he correspondence ad	dress				
A SHORTENED STATUTORY PERIOD FOR REPLY IS THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a), after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply with  - If NO period for reply is specified above, the maximum statutory period will ap  - Failure to reply within the set or extended period for reply will, by statute, caus  - Any reply received by the Office later than three months after the mailing date earned patent term adjustment. See 37 CFR 1.704(b).	In no event, however, may a reply in the statutory minimum of thirty (30 ply and will expire SIX (6) MONTHS se the application to become ABAND	be timely filed  O) days will be considered timely from the mailing date of this coponed (35 U.S.C. § 133).					
1) Responsive to communication(s) filed on 05 April	2002 and 26 August 200	<u>2</u> .					
2a)⊠ This action is <b>FINAL</b> . 2b)□ This a	ction is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.  Disposition of Claims							
4)⊠ Claim(s) <u>1-6,8-19,22-24,26 and 28-30</u> is/are pend	ing in the application.						
4a) Of the above claim(s) is/are withdrawn f	rom consideration.						
5) Claim(s) is/are allowed.							
6) Claim(s) <u>1-6,8-19,22-24,26,28-30</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or ele	ection requirement.						
Application Papers							
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) accepted	or b) objected to by the	Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) The proposed drawing correction filed on is:		pproved by the Examin	er.				
If approved, corrected drawings are required in reply to							
12) ☐ The oath or declaration is objected to by the Exami	ner.						
Priority under 35 U.S.C. §§ 119 and 120							
13) Acknowledgment is made of a claim for foreign pri	ority under 35 U.S.C. § 1	19(a)-(d) or (f).					
a) ☐ All b) ☐ Some * c) ☐ None of:							
<ol> <li>Certified copies of the priority documents have</li> </ol>	ive been received.						
<ol><li>Certified copies of the priority documents have</li></ol>	ive been received in Appli	ication No					
<ul> <li>3. Copies of the certified copies of the priority of application from the International Bureau</li> <li>* See the attached detailed Office action for a list of the action for a li</li></ul>	ı (PCT Rule 17.2(a)).		Stage				
14) Acknowledgment is made of a claim for domestic pr	iority under 35 U.S.C. § 1	19(e) (to a provisional	application).				
<ul> <li>a)  The translation of the foreign language provisi</li> <li>15)  Acknowledgment is made of a claim for domestic process.</li> </ul>	* *						
Attachment(s)							
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449) Paper No(s) 10.</li> </ol>		nmary (PTO-413) Paper Normal Patent Application (PT					

Application/Control Number: 09/692,075 Page 2

Art Unit: 1756

The response provided by the applicant has been read and given careful consideration. Response to the arguments forwarded by the applicant are provided after the first rejection to which they are directed. The appendix has been removed and the information on page 11 of "Photodefinable HD-8000 ...." incorporated properly into the specification and the remainder of the reference is cited on a PTO-1449. There is not issue of new matter in the amendments.

- The following is a quotation of the second paragraph of 35 U.S.C. 112:

  The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- Claims 26,28 and 29 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 26 should indicate that the polyimide transfer medium is cast onto a surface, the data transferred into the transfer medium upon peeling/removal from the data containing surface and then the transfer medium is used to emboss or stamp the data into another surface.

The examiner is of the position that without separating the polyimide transfer materials from the data containing surface, it cannot be used in step b.

In claims 28 and 29, please replace "applying" with --contacting- - .

Claims 3,12,14 and 24 are objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form.

The photo-definable material is already recited as polyimide in claim 10, so claim 14 adds nothing.

Art Unit: 1756

The polyimide is already recited as photodefined in claim 1, so claim 3 adds nothing.

To be a seamless embossing surface, the material must be applied to a roller, therefore claim 12 is superfluous and claim 24 does not fall within the seamless embodiments.

- 5 The following is a quotation of the first paragraph of 35 U.S.C. 112:
  - The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.
- Claims 1-6,8-19,22-24 and 28-30 are rejected under 35 U.S.C. 112, first paragraph, because the specification, while being enabling for rollers or cylinders, does not reasonably provide enablement for other stamper shapes. The specification does not enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to practice the invention commensurate in scope with these claims.

The specification points to seamless cylinders or rollers (5/10-11 and 3/10-4/2), therefore the claims should include this limitation.

- 7 The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8 Claims 1-3,5 and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over McGrew '030, in view of IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987).

McGrew '030 discloses that the transfer layer may be a photoresist applied to the roller from a tank of liquid photoresist, which would not leave a seam in the photosensitive coating

Art Unit: 1756

allowing continuous embossing (2/58-59) and is disclosed as useful in the printing arts. (4/26-38). The use of positive resist is disclosed (3/57-62) After development of the pattern, the pattern may be transferred into the underlying layer by etching.

IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) teaches the formation of a holographic surface relief grating including spin coating a photosensitive polyimide, pre-baking at 85 degrees C, exposing the polyimide with light from a HeCd laser to record the holographic image, and a postbaking/development at 225 degrees C. The polyimide allows dry or wet development, which is disclosed as an advantage.

It would have been obvious to one skilled in the art to modify the process of McGrew '030 by using the polyimide resin and its processing in place of other positive resists with a reasonable expectation of gaining the advantage of being able to use dry (heat) development, which saves on solvents and the need for further apparatus.

The addition of McGrew and/or Fan et al. addresses the issue of seamless printing or embossing mandrels and their advantages as well as modes of coating the rollers.

Claims 1-3,5,6,10-17,22 and 28-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689, in view of McGrew '030, IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) and Kataoka et al. JP 08-039572.

Shvartsman '689 describes the coating of a photohardenable film on a substrate, embossing a pattern into it, curing it while in contact, peeling and transferring the relief image in the photohardened film to another surface by stamping. (8/56-9/21) The use of roller or flat die shapes is disclosed. (9/22-55). See also the examples. Holograms can include images and or text stored holographically.

Art Unit: 1756

Kataoka et al. JP 08-039572 teaches the use of a patterned photosensitive polyimide on the interior surface of a mold. These are pre-heated at 50 degrees and post-baked at 240 degrees

Page 5

in the examples. [0031].

It would have been obvious to one of ordinary skill in the art to use the polymides and process thereof taught by Kataoka et al. JP 08-039572 to form photoresist embossing surfaces as taught by Shvartsman '689 based upon the similarity between molding and embossing within these references and the teachings Shvartsman '689 that photoresist materials are useful as embossing surfaces and the teachings of Kataoka et al. JP 08-039572 that polyimides are useful as molding surfaces. Further, it would have been obvious to use the process with known coating techniques for coating embossing rollers with photosensitive materials as taught by McGrew '030 and processing techniques for pre-curing, exposing, developing and post-curing polyimides such as those taught by IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) with a reasonable expectation of forming a useful image.

Claims 1-3,5,6,8-19,22 and 28-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689, in view of McGrew '030, IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) and Kataoka et al. JP 08-039572, and further in view of JP 01-142077 and/or De Graaf et al. '607.

JP 01-142077 teaches the formation of stampers by electroplating with either nickel or chromium. (abstract)

De Graaf et al. '607 teaches a resist used as a matrix for embossing or molding where the resist is coated with a thin film of Al or Cr. (example II and 5/29-36).

It would have been obvious to modify the processes of Shvartsman '689, in view of McGrew '030, IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) and Kataoka et al. JP 08-039572 by using chrome as the electroformed metal rather than nickel based upon the disclosure of equivalence by JP 01-142077 and/or coating the surface of the resist with thin coatings of metals either to provide a conductive surface for the electroforming as taught by JP 01-142077 or to provide a more robust surface for stamping as taught by De Graaf et al. '607.

Claims 1-6,8-19,22,23 and 28-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689, in view of McGrew '030, IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) and Kataoka et al. JP 08-039572, and further in view of JP 01-142077 and/or De Graaf et al. '607 and Abraham '282.

Abraham '282 teaches the formation of dot matrix gratings or regular gratings in photoresists and the use of these as stampers. (3/11-50)

In addition to the basis provided above, the examiner holds that it would have been obvious to use the processes of Shvartsman '689, in view of McGrew '030, IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) and Kataoka et al. JP 08-039572, and further in view of JP 01-142077 and/or De Graaf et al. '607, such as dot matrix holograms as the image to be formed in the stampers based upon the teachings of the formation of these holograms in stamper surfaces by Abraham '282.

Claims 1-6,10-17,22 and 28-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over either Sassmannshausen et al. '768 or Mueller et al. '736, in view of Fan et al. EP 0766142 and McGrew '030.

Art Unit: 1756

Sassmannshausen et al. '768 teaches the use of positive polyimide resists for fabricating relief structures useful in fabricating microelectronics and printing plates. (1/11-30). Processing of the polyimide resists includes coating, pre-baking at 50-120 degrees C, exposure, aqueous alkaline development and post-baking at 200-400 degrees C. (6/23-7/39).

Mueller et al. '736 teaches the use of positive polyimide resists for fabricating relief structures useful in fabricating microelectronics and printing plates. (4/1-17 and 12/18-32). Processing of the polyimide resists includes coating, pre-baking at 90 degrees C, exposure, aqueous and alkaline development. (example 5).

Fan et al. EP 0766142 describes seamless printing plates, which are useful for printing plates. (5/9-17). The use of printing cylinders allows continuous printing. (2/30-34)

It would have been obvious to one skilled in the art to modify the processes of either Sassmannshausen et al. '768 or Mueller et al. '736 by using the polyimide print surface coated on printing rollers based upon the ability to perform continuous printing and to use the coating processes of McGrew '030 which are disclosed as useful in the printing arts.

Claim 26 is rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689, in view of Kataoka et al. JP 08-039572 and Sassmannshausen et al. '768, and further in view of Muzino et al. '329 and IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987).

Mizuno et al. '329 teaches molding gratings of polyimide. (17/34-38).

It would have been obvious to one skilled in the art to use either molding or direct patterning of the polyimide to form patterns in the polyimide for the purposes of embossing in the process of Shvartsman '689 combined with Kataoka et al. JP 08-039572 and Sassmannshausen et al. '768, based upon the disclosure within the art that the photosensitive

Art Unit: 1756

resins may be either patterned with development as shown in Kataoka et al. JP 08-039572 and IBM Technical Disclosure Bulletin Vol. 30(3) pp. 1392-1393 (08/1987) or photocured in a mold as taught by Muzino et al. '329. The showing of the formation of gratings in particular establishes the equivalence of the techniques within the art.

The examiner notes that the "seamless" limitation does not appear in this claim.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J Angebranndt whose telephone number is 703-308-4397. The examiner can normally be reached on Mondays-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 703-308-2464. The fax phone numbers for the

Page 9

organization where this application or proceeding is assigned are 703-872-9310 for regular communications and 703-872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

Martin J Angebranndt Primary Examiner

Art Unit 1756

October 24, 2002